

RELIABILITY REPORT FOR

DS9503

Dallas Semiconductor

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Prepared by:

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Conclusion:

The following qualification successfully meets the quality and reliability standards required of all Dallas Semiconductor products and processes:

DS9503

In addition, Dallas Semiconductor's continuous reliability monitor program ensures that all outgoing product will continue to meet Maxim's quality and reliability standards. The current status of the reliability monitor program can be viewed at http://www.maxim-ic.com/TechSupport /dsreliability.html.

Device Description:

A description of the device used in this qualification can be found in the product data sheet. You can find the product data sheet at http://dbserv.maxim-ic.com/l_datasheet3.cfm.

Reliability Derating:

The Arrhenius model will be used to determine the acceleration factor for failure mechanisms that are temperature accelerated.

```
AfT = exp((Ea/k)*(1/Tu - 1/Ts)) = tu/ts
AfT = Acceleration factor due to Temperature
tu = Time at use temperature (e.g. 55°C)
ts = Time at stress temperature (e.g. 125°C)
k = Boltzmann's Constant (8.617 x 10-5 eV/°K)
Tu = Temperature at Use (°K)
Ts = Temperature at Stress (°K)
Ea = Activation Energy (e.g. 0.7 ev)
```

The activation energy of the failure mechanism is derived from either internal studies or industry accepted standards, or activation energy of 0.7ev will be used whenever actual failure mechanisms or their activation energies are unknown. All deratings will be done from the stress ambient temperature to the use ambient temperature.

An exponential model will be used to determine the acceleration factor for failure mechanisms, which are voltage accelerated.

```
AfV = exp(B*(Vs - Vu))

AfV = Acceleration factor due to Voltage

Vs = Stress Voltage (e.g. 7.0 volts)

Vu = Maximum Operating Voltage (e.g. 5.5 volts)

B = Constant related to failure mechanism type (e.g. 1.0, 2.4, 2.7, etc.)
```

The Constant, B, related to the failure mechanism is derived from either internal studies or industry accepted standards, or a B of 1.0 will be used whenever actual failure mechanisms or their B are unknown. All deratings will be done from the stress voltage to the maximum operating voltage. Failure rate data from the operating life test is reported using a Chi-Squared statistical model at the 60% or 90% confidence level (Cf).

The failure rate, Fr, is related to the acceleration during life test by:

```
Fr = X/(ts * AfV * AfT * N * 2)
X = Chi-Sq statistical upper limit
N = Life test sample size
```

Failure Rates are reported in FITs (Failures in Time) or MTTF (Mean Time To Failure). The FIT rate is related to MTTF by:

MTTF = 1/Fr

NOTE: MTTF is frequently used interchangeably with MTBF.

The calculated failure rate for this device/process/assembly is:

FAILURE RATE: MTTF (YRS): 17861 FITS: 6.4

The parameters used to calculate this failure rate are as follows:

Cf: 60% Ea: 0.7 B: 0 Tu: 25 °C Vu: 5.5 Volts

The reliability data follows. A the start of this data is the device information. This is a description of the device for this report. Following this is the assembly information. This section includes a description of the assembly vehicle used to generate this reliability data for both qualifications and monitors. The next section is the detailed reliability data for each stress found in the qualification / monitor. If there are additional assemblies used as part of this report, a description of each will follow which includes the respective reliability data for that assembly. The reliability data section includes the latest data available. Some of this data may be generic with other products.

Device Information:

Process: 1P, 1M, 1.2um, ESD-Chip Diode Process, Passivation: Passivation w/Nov TEOS Oxide-Nitride

Die Size: 33 x 44 Number of Transistors: 1

Interconnect: Aluminum / 1% Silicon / 0.5% Copper

Gate Oxide Thickness: 225 Å

Assembly Information:

Qualification Vehicle: DS9503
Assembly Site: Carsem
Pin Count: 6
Package Type: TSOC

Body Size: 150x1.25

Mold Compound: Sumitomo 6300H

Lead Frame: Stamped Copper CDA194

Lead Finsh: SnPb Plate

Die Attach: 84-1 LMISR4 Epoxy Silverfilled Ablebond

Bond Wire / Size: Au / 1.0 mil

Theta JA: Theta JC:

Flammability: UL 94-V0
Moisture Sensitivity Level 1

(JEDEC J-STD20A)

Date Code Range: 9629 to 9629

OPERATING LIFE

DESCRIPTION DATE CODE CONDITION READPOINT QTY FAILS FA#

BIASED BAKE 9629 125C, 7.0 VOLTS 1000 HRS 152 0

Total: 0

TEMPERATURE CYCLE

DESCRIPTION DATE CODE CONDITION READPOINT QTY FAILS FA#

TEMP CYCLE	9629	-55C TO 125C		1000 CYS	80	0	
				Total:		0	
TEMPERATURE HUM	MIDITY BIA	s					
DESCRIPTION	DATE CODE CONDITION			READPOINT	QTY	FAILS	FA#
BIASED MOISTURE	9629	85/85, 5.5 VOLTS		959 HRS	80	0	
				Total:		0	
UNBIASED MOISTUR	RE RESIST	ANCE					
DESCRIPTION	DATE CODE CONDITION		READPOINT	QTY	FAILS	FA#	
AUTOCLAVE	9629	121C, 2 ATM STEAM, UNBIASED		168 HRS	48	0	
				Total:		0	
FAILURE RATE:	N	/ITTF (YRS): 17861	FITS:	6.4			